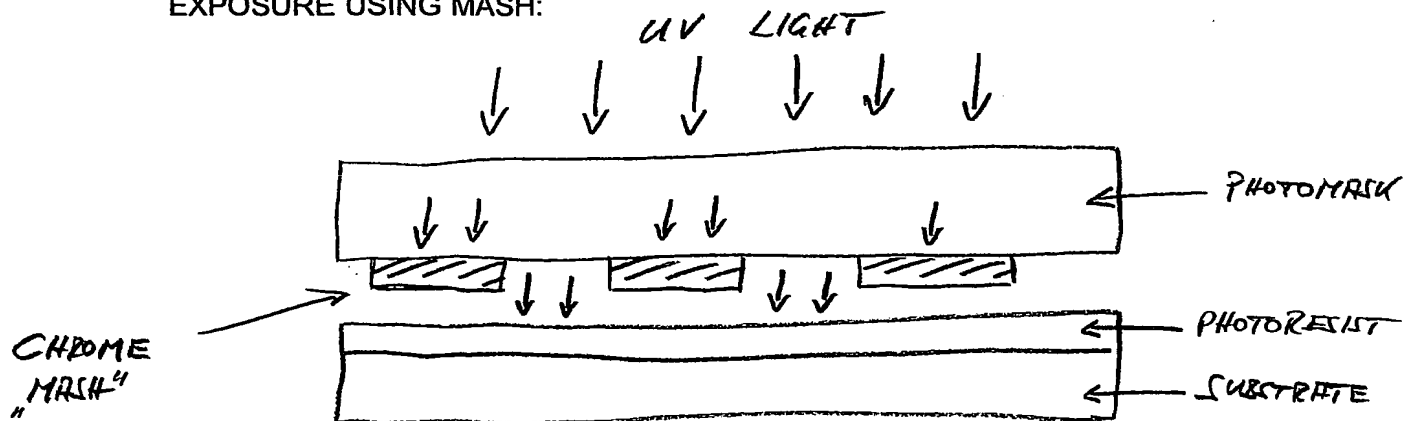


LYNDIN ET. AL:



EXPOSURE USING MASH:



EXPOSURE USING DIRECT HOLOGRAPHIC METHOD USING CROSSED LASER BEAMS:

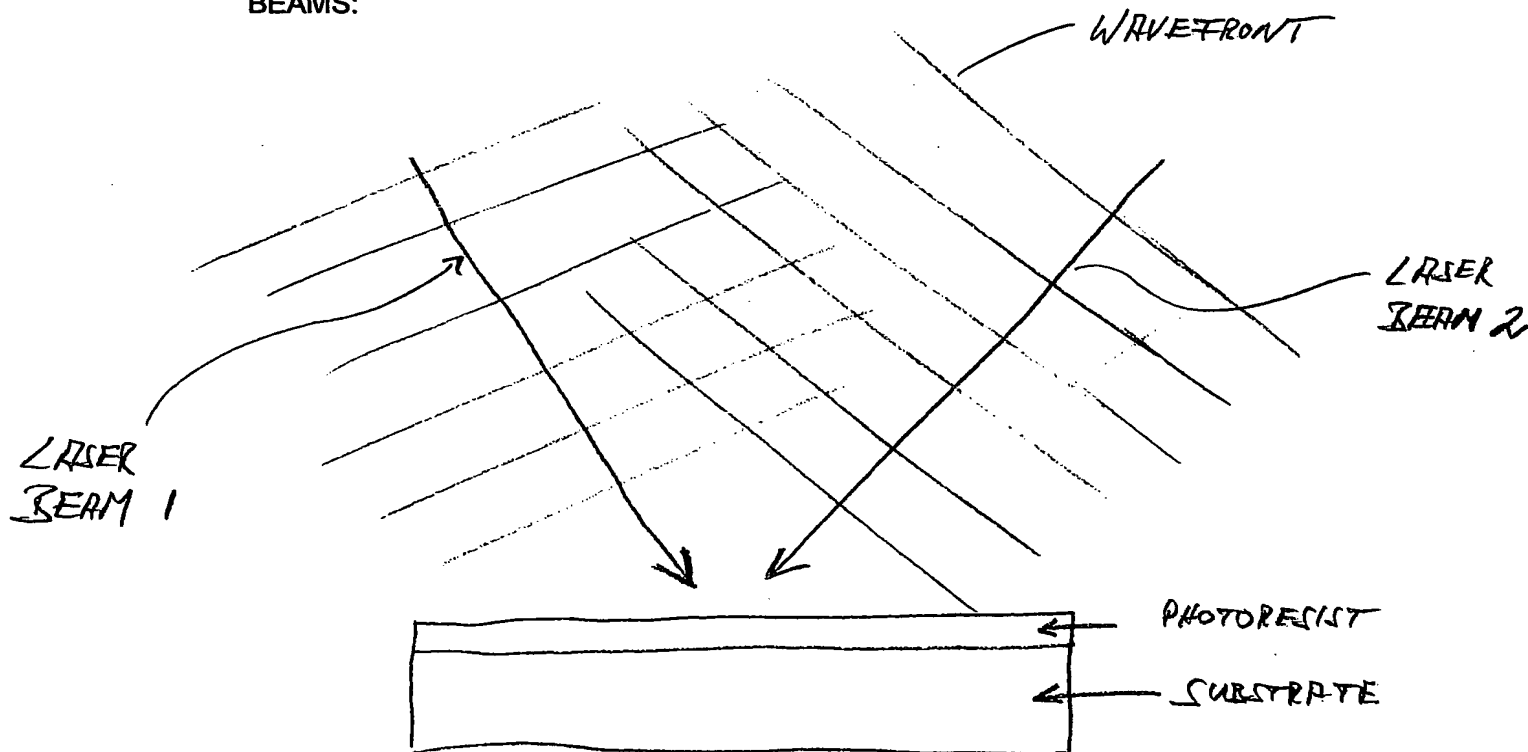
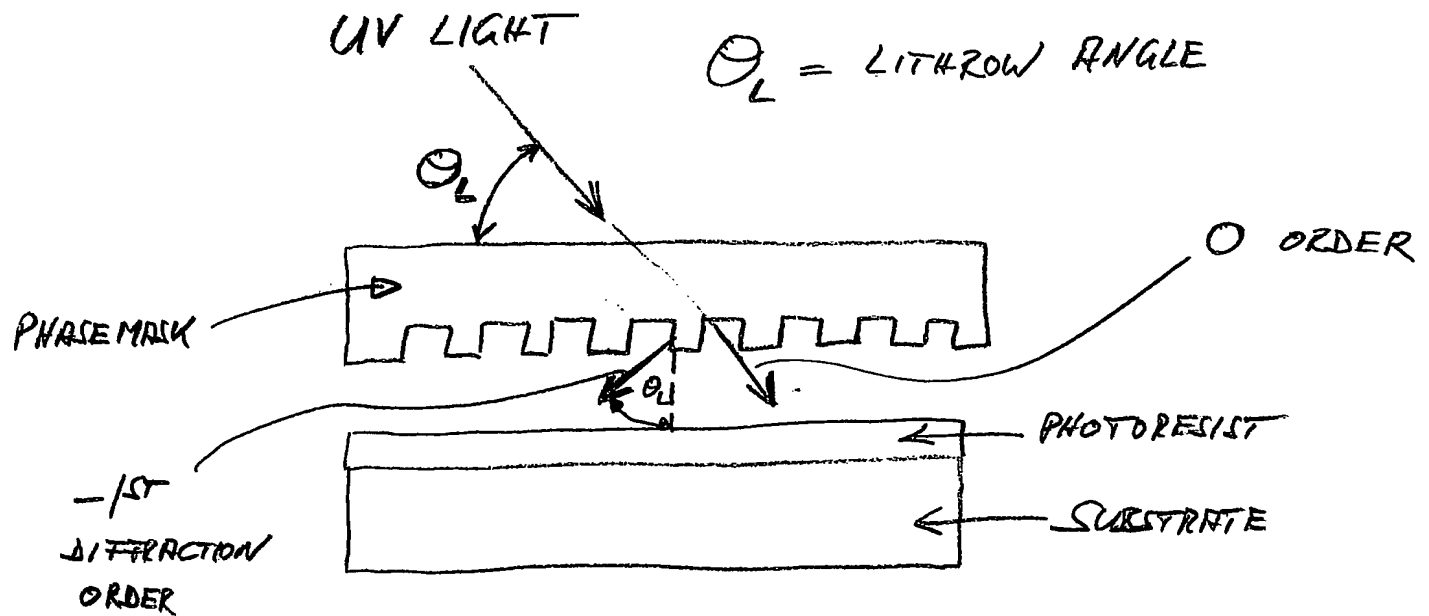


EXHIBIT A

OUR PATENT APPLICATION:

i) LITHROW CONFIGURATION USING PHASEMASK:



ii) NORMAL INCIDENCE USING PHASEMASK.

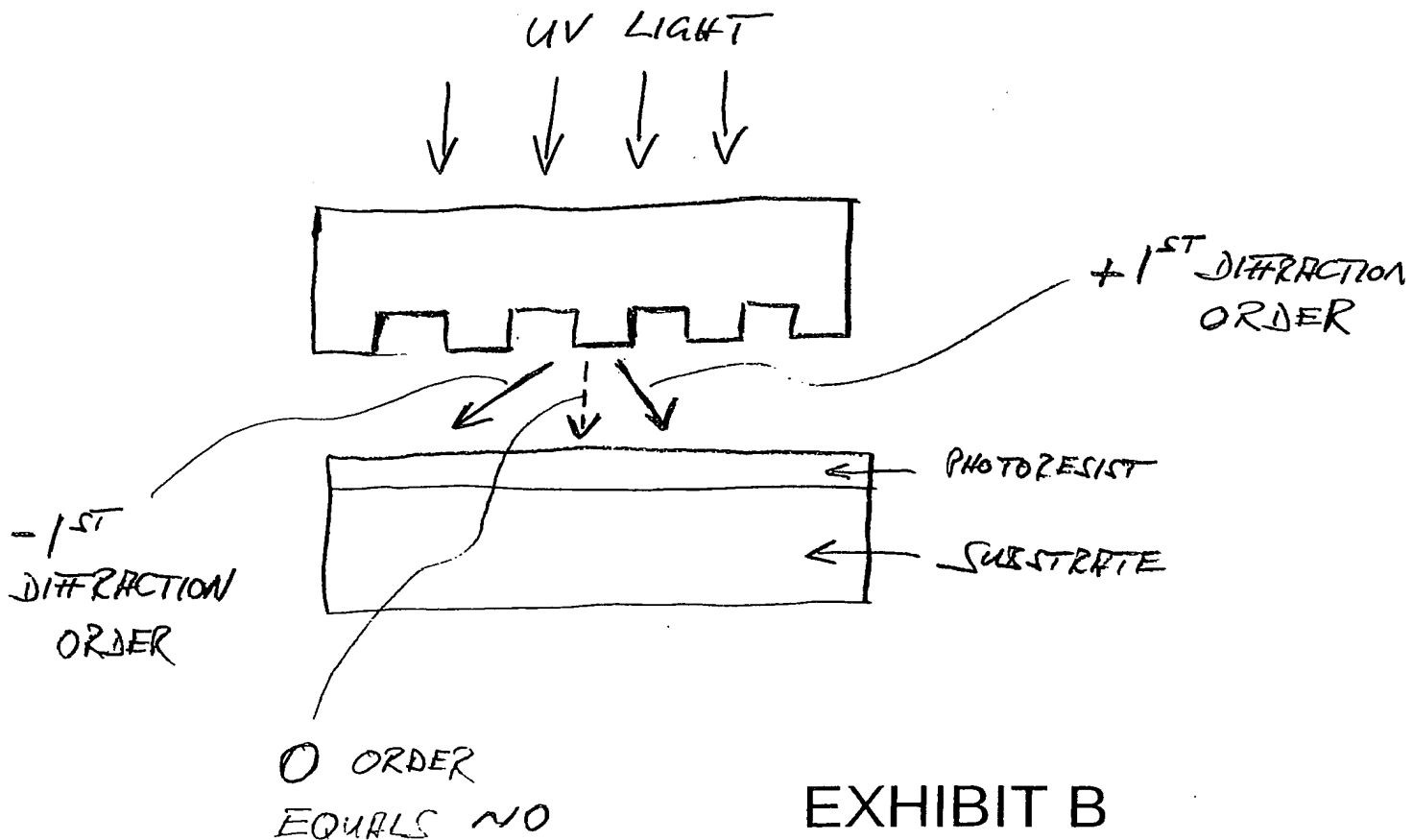


EXHIBIT B